

# PRODUCT RELIABILITY REPORT

**Product: MPQ1918-AEC1** 

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## 1. Device Information

Product:	MPQ1918-AEC1
Package:	14-PIN FC-QFN(3mm×3mm)
Process Technology:	BCD
Report Date:	04/26/2023

## 2. Summary of Test Results

Test	#	Test Condition	Lot# or Date Code	Test Results (S.S./Rej)	Comment
Preconditioning, prior to THB/HAST, AC/UHST, TC, HTSL and PTC	A1	J-STD-020 Reflow: Tp>=260°C, tp>=30sec, 3×reflows	2035 2037 2117	308/0 308/0 308/0 308/0	MSL=1
Temperature Humidity Bias (THB)	A2	JESD22-A101, @85°C/85%RH static bias at Vinmax for 1000 hours or equivalent	2035 2037 2117	77/0 77/0 77/0	
Unbiased Autoclave (AC)	A3	JESD22-A102, @121°C/100%RH for 168 hours or equivalent	2035 2037 2117	77/0 77/0 77/0	
Temperature Cycling (TC)	A4	JESD22-A104, from - 65°C to 150°C for 1000 cycles or equivalent	2035 2037 2117	77/0 77/0 77/0	
Power Temperature Cycling (PTC)	A5	JESD22-A105, from - 40°C to 125°C for 1000 cycles.	HGA700	45/0	
High Temperature Storage Life (HTSL)	A6	JESD22-A103, @150°C for 1000 hours	2035 2037 2117	77/0 77/0 77/0	
High Temperature Operating Life (HTOL)	B1	JESD22-A108, @Tj=150°C for 1000 hours or equivalent	HGA700 HGA703 HP7382	77/0 77/0 77/0	
Early Life Failure Rate (ELFR)	B2	AEC-Q100-008, @Tj=150°C for 48 hours, or equivalent	HGA700 HGA703 HP7382	800/0 800/0 800/0	



Electrostatic	E2	AEC-Q100-002	HP7382	3/0	>2000V
Discharge Human					
Body Model (HBM)					
Electrostatic	E3	AEC-Q100-011	HP7382	3/0	>750V
Discharge Charged					
Device Model					
(CDM)					
Latch-up (LU)	E4	AEC-Q100-004	HP7382	6/0	>+/-100mA &
					>1.5Vccmax

### 3. Failure Rate Calculation

Sample Size: 9550 Rejects: 0 Activation Energy (eV): 0.7

Equivalent Device Hours: 7.45×10<sup>8</sup> Hours

Failure Rate (FIT@60%CL): 1.2 FIT MTBF (years): 92,934 Years

### **Revision / Update History**

Revision	Reason for Change	Date	Rel Engineer
1.0	Initial release	April 2023	Ramon Lei



#### Appendix: Description of Reliability Test and Failure Rate Calculation

**High Temperature Operating Life Test** 

**Purpose:** This test is a worst-case life test that checks the integrity of the product. The high temperature

testing is use for acceleration of any potential failures over time. The calculation for failure rate

(FIT) using the operating ambient temperature is done using the Arrhenius equation.

**Condition:** Tj=150 $^{\circ}$ C @ Vinmax

**Pass Criteria:** All units must pass the min/max limits of the datasheet.

ESD Test

**Purpose:** The purpose of the ESD test is to guarantee that the device can withstand electrostatic voltages

during handling.

**Condition:** Human Body Model and Charged Device Model

Pass Criteria: ESD Testing on every pin. The device must be fully functional after testing and pass the min/max

limits in the datasheet.

IC Latch-Up Test

Purpose: The purpose of this specification is to establish a method for determining IC latch-up

characteristics and to define latch-up failure criteria. Latch-up characteristics are extremely important in determining product reliability and minimizing No Trouble Found (NTF) and

Electrical Overstress (EOS) failures due to latch-up.

**Condition:** Voltage and current injection

Pass criteria: All pins with the exception of "no connect" pins and timing related pins, shall be latch-up tested.

The device must be fully functional after testing and pass the min/max limits in the datasheet.

Moisture/Reflow Sensitivity Classification for Nonhermetic Solid State Surface Mount Devices

**Purpose:** The purpose of this standard is to identify the classification level of nonhermetic solid state surface

mount devices (SMDs) that are sensitive to moisture-induced stress so that they can be properly packaged, stored, and handled to avoid damage during assembly solder reflow attachment and/or

repair operations.

**Condition:** Bake + moisture sock + 3X reflow at 260°C

Pass criteria: All units must pass the min/max limits of the datasheet

**Accelerated Moisture Resistance- Unbiased Autoclave** 

**Purpose:** To check the performance of the device in humid environments. This test checks the integrity of the

passivation, poor metal to plastic seal and contamination level during assembly and material

compatibility.

**Condition:** 121°C/15psig/100% RH (no bias)

Pass Criteria: All units must pass min/max limits of the datasheet

**Temperature Cycle Test** 

**Purpose:** This test is used to evaluate the die attach integrity and bond integrity. This is similar to the

Thermal Shock test, but can generate different failure modes due to the longer dwell time and

gradual temperature change.

**Condition:** -65°C to 150°C

Pass Criteria: All units must pass min/max limits of the datasheet

Steady State Temperature Humidity Bias Life Test

**Purpose:** This is to check the performance of the device in humid environments. This test checks the

integrity of the passivation, poor metal to plastic seal and contamination level during assembly and

material compatibility.

**Condition:** 85%RH at 85°C with Vin=Vinmax

Pass Criteria: All units must pass min/max limits of the datasheet



#### **Highly Accelerated Temperature and Humidity Stress Test**

**Purpose:** This is an equivalent test to Steady State Temperature Humidity Bias Life test with different

(higher) temperature stress condition.

**Condition:** 85%RH at 130°C with Vin=Vinmax

**Pass Criteria:** All units must pass min/max limits of the datasheet

### **Failure Rate Calculation**

The failure rate is gauged by a Failures-In-Time (FIT) based upon accelerated stress data. The unit for FIT is failure per billion device hour.

$$FIT\ Rate = \frac{(\chi^2/2) \times 10^9}{EDH}$$

Where

χ2 (Chi-Squared) is the goodness-of-fit test statistic at a specified level of confidence;

EDH= Equivalent Device Hours =  $AF \times (Life \text{ test sample size}) \times (test duration);$ 

AF= Acceleration Factor.

High Temperature Operating Life (HTOL) test is usually done under acceleration of temperature and voltage. The total number of failures from the stress test determines the chi-squared factor.

$$AF=AF_T \times AF_V$$

The Temperature Acceleration Factor AF<sub>T</sub>:

$$AF_{T} = \exp\left(\frac{E_{a}}{K}\left(\frac{1}{T_{J(use)}} - \frac{1}{T_{J(stress)}}\right)\right)$$

 $T_{Juse}$  = Junction temp under typical operating conditions;

T<sub>Jstress</sub> = Junction temp under accelerated test conditions;

Ea is Activation energy=0.7eV;

K=Boltzmann's constant=8.62×10<sup>-5</sup> eV/K.

The voltage Acceleration Factor AFv:

$$AF_{V} = e^{\beta \times [V_{Stress} - V_{use}]}$$

V<sub>use</sub> = Gate voltage under typical operating conditions;

V<sub>stress</sub> = Gate voltage under accelerated test conditions;

 $\beta$  = Voltage acceleration factor (in 1/Volts) and specified by technology.

Note: For calculation in the report,  $AF_V = 1$  for simplicity.

MTBF (Mean Time Between Failure) equals to 10<sup>9</sup>/FIT (in hours).